

Special Issue

Applications of Nonlinear Optical Devices and Materials

Message from the Guest Editor

This Special Issue, 'Applications of Nonlinear Optical Devices and Materials', will focus on the advances and applications of nonlinear optical devices and materials, including the latest developments regarding these novel materials, their preparation, characterization, mechanisms, optical properties, and applications. We invite researchers, scientists, and experts operating in relevant fields to contribute original research articles, reviews, and perspectives. The topics of interest include, but are not limited to, nonlinear optics, optical materials/devices, nonlinear phenomena, fiber-optics, integrated optics, optical frequency conversion, nonlinear imaging techniques, and photonic devices.

Guest Editor

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As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal *Applied Sciences* has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

Editor-in-Chief

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